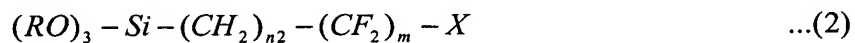


### Abstract of the Disclosure

Provided is a method of treating a surface of a substrate used in a biochemical reaction system, the method including forming a polymer film on the surface by vapor deposition of a compound of formula (1) below and a compound of formula (2) below:



wherein  $R$  is one of a methyl group and an ethyl group,  $X$  is one of a methyl group and a trifluoromethyl group,  $n1$  is an integer from 1 to 3,  $n2$  is an integer from 1 to 10, and  $m$  is an integer from 1 to 10.